



Review

Laser Scribing of Photovoltaic Solar Thin Films: A Review

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Abstract: The development of thin-film photovoltaics has emerged as a promising solution to the global energy crisis within the field of solar cell technology. However, transitioning from laboratory scale to large-area solar cells requires precise and high-quality scribes to achieve the required voltage and reduce ohmic losses. Laser scribing has shown great potential in preserving efficiency by minimizing the drop in geometrical fill factor, resistive losses, and shunt formation. However, due to the laser induced photothermal effects, various defects can initiate and impact the quality of scribed grooves and weaken the module's efficiency. In this regard, much research has been conducted to analyze the geometrical fill factor, surface integrity, and electrical performance of the laser scribes to reach higher power conversion efficiencies. This comprehensive review of laser scribing of photovoltaic solar thin films pivots on scribe quality and analyzes the critical factors and challenges affecting the efficiency and reliability of the scribing process. This review also covers the latest developments in using laser systems, parameters, and techniques for patterning various types of solar thin films to identify the optimized laser ablation condition. Furthermore, potential research directions for future investigations at improving the quality and performance of thin film laser scribing are suggested.

Keywords: laser scribing; thin film solar cell; quality analysis; laser scribing defects; power conversion efficiency

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1. Introduction

The development of energy technologies with fewer environmental problems than the current fossil fuel-based systems is required due to the environmental issues caused by greenhouse gas emissions [1,2]. Solar cell technology is one of the most critical areas in the renewable energy field. It also plays a vital role in producing electricity because of the increasing demand for energy due to the rapidly growing world population [3].

The technology of solar cells has advanced significantly in the past decades. Crystalline solar cells have been used for a long time and can meet regular efficiency needs. Efficiencies of 26.8% and 23.3% have been obtained in the laboratory for monocrystalline and polycrystalline silicon solar cells, respectively [4]. However, the production costs are still high. Therefore, thin film technology has been developed to minimize material usage [5]. Amorphous silicon, cadmium telluride (CdTe), and copper indium gallium selenide (CIGS) are significant types of solar thin films that have dominated the solar thin film market [5,6]. Moreover, new generations of solar thin films with different materials have been developed rapidly in recent years to address various challenges such as production costs, industrial volume compatibility, long-term stability, environmental problems, and increasing efficiency [7,8].

Three scribing steps must be developed to reduce photocurrent and resistance losses in thin film solar technology to create the monolithic serial interconnections between the submodules [9,10]. These steps are effective approaches to reducing ohmic loss.

Furthermore, the serial interconnection structure limits the solar cell's output current and increases the output voltage [11]. To achieve the laboratory efficiency and performance established for less than 1 cm² cell area, a high active surface area exceeding 95% of the total sub-module area is required to increase solar cell efficiency [8]. Over the years, laser scribing has been developed for this purpose in manufacturing solar thin films because it is environmentally friendly and has good capabilities for industrialization due to its unrivaled speed in producing monolithic interconnections [8,9].

Using lasers in patterning thin films and electronic devices dates back to the late 1960s when lasers were used for trimming electronic devices and precise cutting of thin films, which was elaborated by the early review of Levinson and Smilga [12]. Afterward, laser rapidly became one of the most efficient tools in thin film modification and scribing due to its remarkable characteristics in patterning materials compared to conventional methods. Nakano et al. [13] used laser for scribing amorphous silicon solar cells for the first time. Similar studies extended to the patterning of different types of materials used in solar cells, including CdTe, CIGS, ZnO, SnO₂, Mo, Al, and Au thin films [14]. Bartlome [15] reviewed laser-based operations, particularly for chalcogenide photovoltaic solar cells, including laser treatment, characterization, scribing of photovoltaic devices, and laser diagnostics during the deposition of Si thin films until 2010. In recent years, extensive laser scribing studies have been performed on new generations of solar cells, mainly focusing on perovskite solar cells [8,16]. In addition, Bonse and Krüger [17] reviewed ultra-short laser structuring, especially for metal, semiconductor, and dielectric thin films, by highlighting and emphasizing ablation mechanisms. Despite the reviews mentioned earlier regarding the variety of thin film laser scribing, much progress has been made within the past two decades, which has not been well documented. Therefore, a thorough assessment of the laser scribing process applied to various types of thin-film solar materials during this time frame is needed.

This paper aims to review the progress made in the past decades in laser scribing of all kinds of thin film solar cells. In this work, we focus on the studies of non-silicon-based thin film solar cells such as CIGS, CdTe, and perovskite cells, followed by a summary of major accomplishments, remaining challenges, and future research directions. First, a brief history of solar cells and their fabrication is presented. Then, the essential need for laser scribing in solar cells, especially in thin film photovoltaic (PV) devices, is introduced. Subsequently, the critical challenges and progress made in laser scribing and the impact on scribing quality and surface integrity are discussed. Finally, a summary of the achievements in laser scribing various PV thin films is presented, accompanied by suggestions for potential future research directions.

2. Types of Thin Film Solar Cells

Despite the dominance of crystalline and polycrystalline silicon cells in the solar photovoltaics market, attempts to produce more cost-effective solar cells with minimum material usage while maintaining acceptable efficiency have led to the employment of thin films in this area. Thin film PV cells, often referred to as the second generation of solar cells, can be lightweight and flexible due to their much thinner structure than silicon cells. In thin film solar cells, the typical thickness for the two conductive layers is typically a few hundred nanometers. The thickness of the middle absorber material can vary from a few hundred nanometers to a few microns, depending on the specific type of solar cell [18]. Economic material usage and waste reduction have led to more cost-effective production of these PV types [5]. However, the efficiency of thin film PV cells is generally lower than that of crystalline silicon solar cells.

Amorphous silicon (a-Si), cadmium telluride (CdTe), and copper indium gallium selenide (CIGS) are among the most common types of thin film PV cells, with reported efficiencies of 14%, 22.1%, and 23.6%, respectively [4]. In addition, new generations of thin films, such as copper zinc tin sulfide (CZTS) and perovskite, have already been developed in the last few years but have not been commercialized. However, perovskite has shown

the fastest improvement in efficiency among all types of solar cells reported by NREL, with a record efficiency of 25.8% [4].

Next-generation thin film PV technology is advancing through the development of bifacial solar cells, PERC silicon solar cells with back-surface passivation layers, and tandem or hybrid solar cells with multijunction structures [19]. Furthermore, nanomaterials, such as quantum dots and 2D materials, offer the potential to control layer morphology, enhance charge transport and bandgap tunability, and improve durability in thin film structures [20–24]. Overall, the use of nanomaterials in thin film solar cell technology shows promise for enhancing cell performance.

Laser scribing is a highly beneficial tool in the fabrication of thin-film solar cells, which typically consist of multiple layers of materials deposited on a substrate. However, unique outcomes in the laser scribing process can arise due to differences in material properties, film thickness, and solar cell structure, necessitating specific laser scribing systems and conditions. In this regard, achieving maximum efficiency requires a thorough understanding of solar cell material response to the laser scribing process. Nonetheless, laser scribing is a promising technique for commercializing new generations of solar cells, including perovskite, which requires further investigation due to its compositional complexity.

3. Scribing Processes in Thin Film Solar Cell Manufacturing

3.1. Fabrication and Patterning of Solar Thin Films

Thin film solar cell manufacturing involves many processing steps, including multiple film deposition processes and three scribing steps, known as P1, P2, and P3, which define individual cells and interconnect adjacent cells electrically in series to reduce the current and ohmic losses and increase voltage [9]. As illustrated in Figure 1, P1 provides a complete cut in the back conductive layer on the substrate. It is a perfect electrical isolation step to create essential cell separation [25]. P2 scribing removes the absorber layer on the back contact layer. It is performed to create electrical contact between the back and front conductive layers and to achieve current flow between adjacent submodules [26,27]. This scribe is usually performed after the deposition of the absorber layer on the back contact layer [27]. Finally, the purpose of the P3 scribe is to remove a line on the front contact layer to complete the isolation, similar to the P1 scribing. However, sometimes both the front contact film and the absorber layer are intentionally removed to ensure this layer's complete isolation [11]. Figure 1 is a schematic illustration of P1, P2, and P3 scribing to define the individual cells and generate the monolithic serial interconnections.

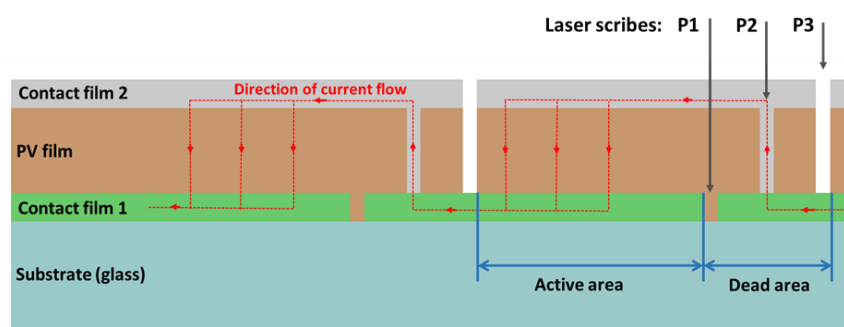


Figure 1. Schematic illustration of a PV cell's performance and three scribes in a PV device to create the monolithic serial interconnection.

The distance between the P1 scribe and the P3 scribe is called the “dead area”, as it is demonstrated in Figure 1. Since the dead area does not contribute to generating electricity, this region must be as small as possible to increase the active area (spacing between the P3 and next P1 scribe). Therefore, the position and width of every pattern are critical

factors in improving the PV cell's performance and the PV photovoltaic region's practical use [27]. In addition, scribing should possess a high degree of precision in depth control, allowing for selective removal of the intended thin film while preserving the integrity of underlying layers [18]. The scribes should be clean and free from damage, especially for P2, since it interconnects the top and bottom contact. The absorber film is also the thickest among the three films. If it is not completely removed, the electrical resistance between cells will increase, resulting in efficiency loss. Hence, P2 scribing is the most challenging step. Finally, laser scribing should be done at high speeds to increase productivity.

3.1.1. Mechanical Scribing

Mechanical scribing is one of the conventional ways to generate monolithic serial interconnections. This technique uses a needle to scratch the material off the underlying deposited layer and create a channel with a width of hundreds of microns and a penetration depth of about 500 μm [28]. The needle pressure provides the required tension to separate the material, which finally causes delamination and chip formation [29]. This method is developed chiefly for P2 and P3 scribing due to the sensitivity of the underlying material, which requires high accuracy. Although this method has provided high efficiencies [30,31], there are some limitations and disadvantages. Since the scratching technique is implemented by a mechanical tool, it is always exposed to wear and tear. Consequently, a replacement system for changing the needles should be established. Furthermore, uncontrolled breakout and inaccuracy are other issues that can occur based on the ductility and adhesion of the material [32]. In ductile materials, piling-up may occur on the two sides of the scribed grooves [29]. So, the adjacent scribe should be scratched further from the inhomogeneous groove to avoid overlapping the scribes. Therefore, the dead area distance will be increased. While mechanical scribing is a traditional approach with acceptable quality, the demand for high efficiency, precise scribing, and high process speed has led thin-film PV technologies to employ much more precise and high-tech alternatives.

3.1.2. Laser Scribing

Utilizing lasers for scribing has solved many problems researchers were confronted with in mechanical scribing. Figure 2 compares two mechanical and laser scribes. As can be seen, the inhomogeneous scribe from mechanical scribing has been accompanied by debris and breakout of material from its main direction; however, laser irradiation has provided a cleaner and more accurate pattern with less debris formation [29].

In addition to producing narrow scribes with straight walls, laser scribes should be clean and devoid of any thermomechanical and chemical damage. Several investigations have proved the generation of shunt resistance between the two back and front contact layers due to the melting of the middle absorber layer having metallic elements. Mini-crack formation, the heat-affected zone (HAZ), diffusion, and debris formation are typical issues that influence the surface integrity of the scribes. Since laser scribing is a thermo-mechanical technique, understanding the melting, evaporation, and plasma formation mechanisms can help researchers optimize the process.

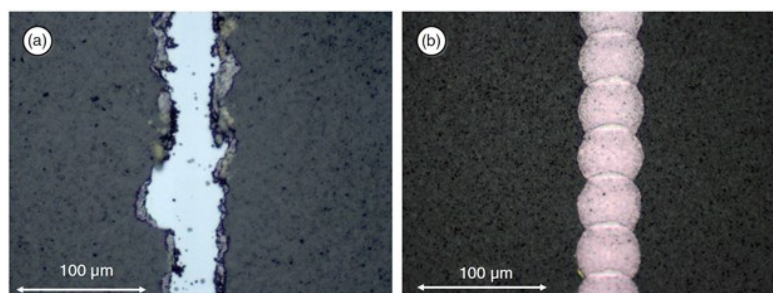


Figure 2. Comparison of the scribes performed by two different techniques, (a) mechanical scribing and (b) laser scribing [33].

Thin Film Laser Scribing Mechanisms

In general, laser irradiation causes the excitation of optically active states of the film, which leads to induced photon energy thermalization, photochemical reactions to break down the bond, stimulated molecules' fragmentation, and finally, ablation of the entire layer [34]. These interactions can be divided into three major laser ablation processes in solid films, including thermal, photochemical, and thermomechanical ablations [34,35]. Although one of the mentioned mechanisms dominates laser processing, two or three cases typically contribute to laser ablation [34]. If the thermalization time is less than the excitation process of breaking the bond, the mechanism is known as thermal or photo-thermal ablation. It means that induced light is converted to the lattice as vibrations, leading to heat dissipation and phase change before the bond breaking can release molecules from the material surface. However, photochemical ablation is the dominant process if the thermalization time is longer than the initial excitation interaction. This process is accompanied by extensive excitation, chemical bond breakage, and disintegration of the molecules, which can effectively reduce the heat-affected zone. Using short-wavelength lasers has been shown to lead the scribing mechanism to chemical bond breaking and photochemical decomposition of molecules caused by the high photon energy [36]. It has been reported that in ITO and ZnO femtosecond UV (ultraviolet) laser scribing of the P1 layer with lower fluences, photochemical ablation is dominant; however, increasing pulse fluence can push the scribing process to thermal ablation [37].

Thermomechanical or stress-assisted ablation is governed by high internal thermal stress leading to rapid expansion, mechanical fracture, spallation, and micro-explosion of the material by pressure plasma. Studying ablation regimes, scientists observed that mechanical ablation dominates when the laser pulse duration is less than the mechanical relaxation (expansion) time [38]. The molecular dynamics (MD) simulations also confirm that shorter laser energy deposition time can lead to stress confinement in the material and thermomechanical spallation [39]. Weber et al. [40] showed that nonthermal ablation typically occurs in the grooves' inner and central parts, while the crater's outer parts are more exposed to thermal effects and melting. Furthermore, it was reported that while there is no apparent advantage of using short pulse lasers in thermal ablation regimes, using short pulses can be more beneficial in P2 and P3 scribing to reach dimensional and geometrical accuracy [41]. Ultrashort lasers have also minimized the HAZ, recast layer, and microcracks by decreasing thermal diffusion and melting, leading to nonthermal ablation. Hu and Shin [42] confirmed that using a picosecond (ps) pulse duration helps to improve the surface quality in solar cell laser ablation by reducing thermal effects. Subsequently, Bian et al. [43] showed an almost nonthermal ablation of ITO-coated glass using a femtosecond (fs) laser with 800 nm wavelength irradiation, resulting in deep and narrow scribes with minimum defects.

Besides front-face scribing, laser rear-side or induced ablation removes material through laser-induced mechanical fracture and spallation. The lift-off process of CZTS can be performed by a ps infrared laser that is about ten times more efficient. With this technique, fine-quality scribes are obtained through stress-ablated material, which minimizes melt formation at the edges of the scribes [44]. This mechanical ablation reduces the damage threshold as well. The experimental results of perovskite thin film P2 scribing illustrate that the stress-assisted micro-explosion mechanism has initiated the ablation at significantly lower threshold fluences [45]. As the article demonstrates, compared to film-side illumination, it has enabled the process to reach much narrower grooves with a reasonable repetition rate and overlap [45]. At the same time, explosion and thermal stress would cause irregular scribe geometry and micro-cracks that can lead to lower photoconversion efficiency [46]. Furthermore, in the case of induced ablation, selecting an appropriate laser wavelength is particularly critical due to the need for the laser energy to pass through the glass, TCO, or both, depending on the type of patterning and the solar cell structure.

Despite the significant progress in the field of laser–matter interaction, our understanding of the underlying physics of laser thin film scribing is still incomplete [47]. Scribing thin films can demonstrate unique characteristics compared to thick layers or bulk ablation because their optical characteristics deviate from bulk material. This deviation is due to the fact that decreased layer thickness is comparable to optical penetration depth [48]. The amount of absorbed and conducted energy will then differ from the bulk. In laser scribing, when the pulse duration exceeds the electron–phonon relaxation time, then the heat starts diffusing into the surrounding material, followed by transferring of electrons' energy to the lattice and thermalization between the electrons and the lattice. In this case, since heat conduction in thin films is smaller than in thick layers, it leads to weak heat dissipation, accelerating evaporation in thin film ablation rather than melting [37,49]. Therefore, decreasing the layer thickness is accompanied by increasing the surface temperature [50]. On the other hand, the damage threshold of laser ablation can be affected by film thickness [17]. Using single pulse laser ablation with a 248 nm wavelength and 14 ns pulse duration, Matthias et al. [51] determined a film thickness dependency of ablation threshold (for the film thickness of metals between 50 nm and 7 μm). It was revealed that the damage threshold increases linearly with increasing film thickness for a small layer thickness less than the material's thermal diffusion length (L_{th}). However, the damage threshold is almost constant for higher values than L_{th} . Thinner films have been observed to impede the diffusion of electrons, which results in a delay in electron–phonon coupling and subsequently lowers the damage thresholds [52]. These results have been achieved for femtosecond laser ablation of various metallic materials with 515 and 1026 nm wavelengths. Experimental and simulation results indicate that optical penetration depth is the critical point for the transition from thin-film scribing to the asymptotic behavior of bulk laser ablation [52]. Another challenge of thin-film scribing is the influence of substrate material on threshold fluence. This impact has been observed to be more dominant in the laser ablation of films with less than 100 nm thickness [53]. In this case, laser scribing on sapphire has been shown to cause much more film thickness dependency and higher threshold influence than fused silica and polymeric substrate (PMMA), and laser film ablation on PMMA has led to the lowest damage threshold fluency in this research.

4. Towards High-Performance Laser Scribing of Thin Film Solar Cells

The extensive research work conducted over the years in thin-film laser scribing has been driven by the desire to maximize their conversion efficiency and minimize production costs. In this section, the progress made along this journey is documented through the lens of scribe quality in terms of scribe geometry, surface integrity, chemical stability, and cell performance.

4.1. Scribe Geometry

Thin film laser scribing uses different parameters that may lead to particular ablation geometries. Examination of scribe width, scribe depth, scribe cross-sectional profile, and depth selectivity are the main categories of assessing geometrical quality. Reducing scribe width and dead area from hundreds to tens of microns has been a constant goal for researchers to maximize the active area in solar cells. Furthermore, selectively removing only the desired layers with steep scribe walls has been investigated to enhance the performance of the solar cells and reduce resistance losses. To meet these demands, researchers have utilized different laser sources, parameters, and scribing techniques based on the thermal and optical properties of the material to minimize electrical losses and achieve high quality scribes.

- Scribe depth selectivity and cross-sectional profile

Selective laser scribing is an essential feature of assessing the scribe quality, which is strongly impacted by laser parameters [54]. It has been referred to as a scribing process in which a desired depth or layer is ablated entirely without removing or damaging the

underlying material [29]. Using various laser sources with different wavelengths and laser fluences, Compaan et al. [14] examined scribing depth for a wide range of metallic and semiconductor thin films. Laser wavelength was found to be an efficient factor such that selective removal of a specified layer thickness was feasible utilizing UV lasers with lower fluences. These experiments showed that the 355 nm UV light source could obtain complete and high-quality ablation with narrow groove width, due to the match between the photon energy and the material band gap energy. On the other hand, however, for the IR (infrared) laser source, poor groove profile quality has been shown because of the material pile-up on the edge of the scribes due to thermal influences [14].

Applying high laser intensities and overlapping ratios was found to directly impact crater depth, groove width, and the total ablated area, which has been verified in laser patterning of CIGS and a-Si solar cells [55,56]. However, ridge height must be addressed due to high laser fluences [14]. This phenomenon was also observed for a-Si and ITO ablation using nanosecond (ns) lasers [56,57]. It must be stated that since after P3 ablation, there is no deposition, these protrusions should not highly affect electrical performance. However, for P1 and P2, it may be more challenging to avoid efficiency reduction [58]. It was reported that this problem could be suppressed by using a large beam radius [59].

Schultz et al. [60] employed a ns laser for CIGS P2 scribing, but when a low fluence (less than 0.30 J/cm²) was applied, the resulting scribe was incomplete and of poor quality, with surface bulging observed. Additionally, higher fluences (more than 0.40 J/cm²) caused removal and damage of the molybdenum (Mo) front contact layer. Both conditions led to high series resistances; however, setting up the laser fluence in a moderate range has improved the quality of laser scribes. Shin et al. [61] investigated laser scribing of the CIS layer on Mo at different laser fluences and scanning speeds to precisely ablate the whole layer without damaging the material beneath. Accordingly, it was observed that decreasing the scanning speed will increase the ablation depth and width by melting the outer parts of the spot. It was also determined that using ultrashort pulse lasers was necessary to completely ablate the entire layer and avoid damage to the underlying films [61]. Furthermore, fs lasers can also be more efficient in reaching this goal [62]. Incomplete ablation can also impact the fill factor (FF) and current extraction in solar cell structures. This problem was actually shown to be more crucial in perovskite solar cells with a thin TiO₂ scaffold interlayer between the absorber and front contact layer [63].

Scribe depth was also examined in fs single pulse irradiation of ITO on glass. The analysis by a 3D profiler demonstrated that different pulse overlaps could lead to various groove profiles. It was shown that increasing the overlap ratio from 33.2% to 98.7% could alter the scribe profile from a V shape to a U shape with steep side walls. Furthermore, to achieve desired topographical and electrical characteristics, it was illustrated that the laser scanning rate must be lower than 50 mm/s to uniformly ablate the ITO with a pulse fluence between 0.66 and 2.3 J/cm² [43]. However, flake formation has been reported for higher overlap ratios due to a high repetition rate and reduced scanning speed, which can be a limitation to any scribe quality gain [64].

Researchers have proposed induced ablation as an alternative laser scribing technique to achieve highly selective film removal and steep wall scribes. Employing this approach for scribing CZTSe thin-film solar cells with an IR ps laser has improved removal quality, selectivity, and crater edge quality without the presence of defects [44]. Kuk et al. [65] applied induced ablation for P2 scribing of CIGS on TCO film using a 532 nm ns pulsed laser to avoid damage in the back contact layer. This research thoroughly investigated the effects of laser beam size and beam shaping. As shown in Figure 3 for P2 scribing with different beam shapes, laser fluences, and scanning speeds, the scribe width is smaller in the 24 µm beam spot, but controlling the process to prevent ITO damage is challenging. Employing a 64 µm beam spot size overcame this issue with the added benefit of increased scanning speeds. Moreover, using an elliptical shaped beam (21 × 84 µm) could suppress ITO damage, accompanied by narrower width, more straight grooves, and higher scanning speeds [65]. A similar induced ablation study using a ps laser confirmed

the advantage of using an elliptical beam for selective film removal and high-quality scribes. Elliptical beams can also reduce the need for high beam overlapping ratios, which is an excellent asset for high-speed laser scribing and industrialization [66].

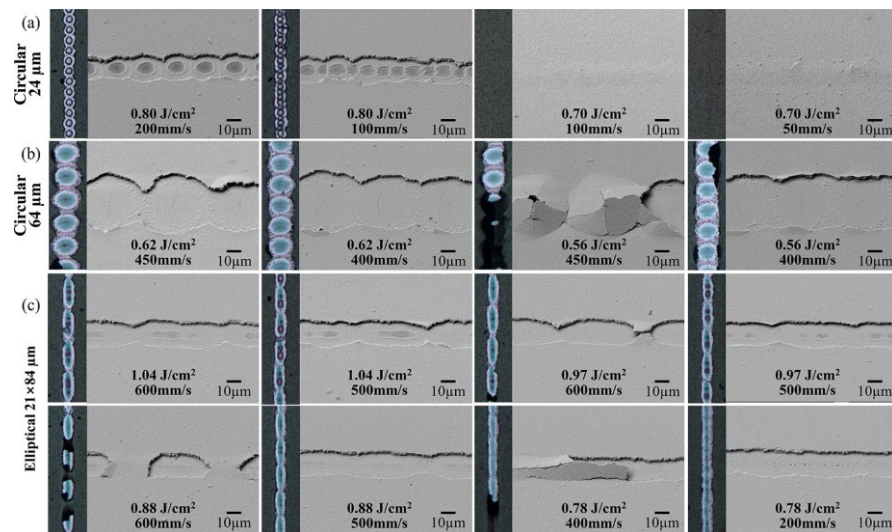


Figure 3. P2 line scribing results by (a) 24 μm diameter circular beam, (b) 64 μm diameter circular beam, and (c) 21 $\mu\text{m} \times 84 \mu\text{m}$ elliptical beam. An optical microscope and a 30° tilted SEM image are shown for each condition with laser fluence and scribing speed marked [65].

- Laser scribing width and dead area

A simulation study on monolithic series interconnections in thin films revealed that the dead area should not be increased since it can compromise the active area and electrical efficiency [67]. It has been observed that for an active area width of 6 mm, by reducing the dead area width from 3000 to 500 μm , the total efficiency loss decreases from about 35% to 10% [67]. However, it has been demonstrated that a trade-off is also necessary for the optimization of scribe width based on the different material sheet resistance [68]. The loss factors based on the active and dead areas have been broken down into three categories, including (1) geometrical losses due to the dead zone, (2) resistive losses due to TCO, and (3) resistive losses for P2 interconnection [69–71]. It was revealed that reducing the P1 scribe width from the optimum point in low-resistance solar cells has dropped the efficiency [72]. Consequently, decreasing the dead zone ratio to the total area without generating resistive or shunting losses is required [73].

To reduce the scribe width, using lasers with beam quality factor M^2 less than 1.3 is generally recommended [74,75]. Short wavelengths are also beneficial, as demonstrated by the results of UV laser scribing of P1, P2, and P3 for microcrystalline silicon thin film, which has led to integrated width of less than 500 μm [76]. By adjusting laser peak power, focus, and pulse width for laser scribing of silicon thin films, it was demonstrated that a 150 μm dead area width with 30, 45, and 50 μm separation could be obtained for P1, P2, and P3 ablations, respectively [77]. Furthermore, by utilizing lift-off ablation for P1 and P3 and direct ablation for P2 on CIGS solar cells, a small PV device with an initial efficiency of 18.3% was transformed into a large-area module with an efficiency reduction of less than 10%. This progress was achieved by creating a dead zone of approximately 70 μm , composed of 10, 10, and 34 μm width for P1, P2, and P3 scribes, respectively, and about 8 μm distance between adjacent scribes [26]. Heise et al. [66] used a ps laser for all three patterning processes for CIS solar thin films, with P1 being direct and induced ablation, P2 direct ablation, and P3 indirect induced ablation (removing material by lift-off from front TCO film side specifically in CIGS and CZTSe structures). Utilizing ps pulses led to narrow grooves and prevented thermal damages to the underlying layer compared to ns laser for P1 scribing, resulting in reduced dead area. Moreover, using ultrashort laser

pulse irradiation, researchers reached much more constant width and cleaner scribes with minimal flake formation and delamination compared to a ns laser source [78,79]. Ultimately, using a ps laser source has shown an excellent capability to decrease the P2 CIGS scribe width to 10 μm [79].

Results of photoluminescence imaging for P2 scribing of CIGS and perovskite show that P2 scribing of perovskite leads to wider crater diameters. The wider crater is due to the fact that the significant difference in thermal conductivities between the very thin perovskite layer (650 nm) and the ITO film causes heat accumulation that expands through the interface. This problem has been a barrier to enhancing the geometrical fill factor in perovskite [80]. Moon et al. [67] performed all scribing steps of organometallic halide perovskite solar modules by laser for the first time; however, the 820 μm of dead zone width reduced the geometrical fill factor to about 16%. For laser scribing of SnO₂-based perovskite with a UV ns laser, to guarantee a complete interconnection, the dead area could not be reduced to less than 600 μm [81]. Using laser for scribing P1 and mechanical scribing for P2 and P3, the dead area has been reduced to 235 μm in a cell stripe of 4.7 mm in a multijunction perovskite/CIGS thin film, which reduced the power conversion efficiency (PCE) loss to about 5% [82]. Walter et al. [63] used a UV laser for P1 glass side ablation, a green laser for glass side P2 and film side P3, and the dead area width reached about 400 μm (about 8% reduction in geometrical fill factor) for perovskite solar cells. In 2021, Yoo et al. [83] used a 532 nm ps laser that narrowed down P1, P2, and P3 scribes to 25, 105, and 80 μm scribe width, respectively; it led to a geometrical fill factor of 94.36%, efficiency of 20.4% for a mini-module, and power conversion efficiency of 17.53%. However, in 2020, Gao et al. [84] demonstrated that using ns lasers can still be a practical technique for perovskite solar cells because the absorber material has a small thermal diffusion coefficient. Moreover, the results showed a sufficient reduction of the dead area to 270 μm and a geometrical fill factor of 95.5%.

Rakocevic et al. [85] introduced a point contact interconnection design to reduce geometrical fill factor losses. Using this strategy instead of the classical line contact method was found to be promising to reduce interconnection losses to 1% and reach a geometrical fill factor of up to 99%. Figure 4 illustrates the main structural differences between point contact interconnections and classical interconnections. The design structure of this P1/P2/P3 type patterning was achieved through numerical and analytical work to approach the theoretical limit. However, the emphasis has been on demonstrating the feasibility of achieving this limit rather than developing a reliable method for reducing losses in perovskite modules [86].

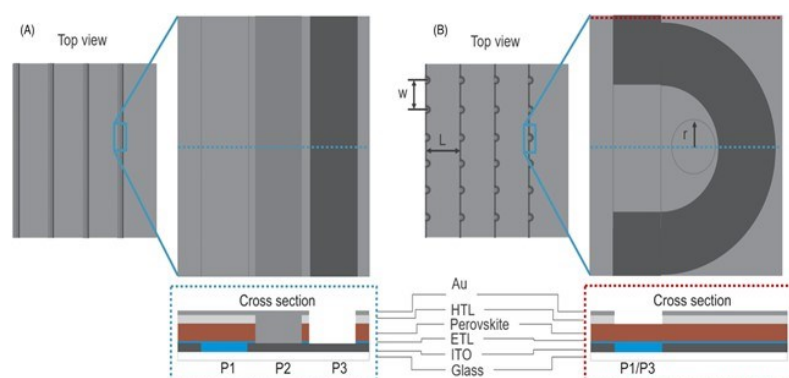


Figure 4. Top view and cross section of a solar module with four cells connected in series with a magnified view of (A) classical and (B) point contact interconnections. Blue and red dotted lines indicate where the cross sections are taken. The red dotted cross section represents the part of the point contact interconnection where the P1 and P3 interconnections overlap [85].

4.2. Microstructure and Surface Morphology

Damages are commonly observed in laser scribing of solar thin films, including the heat-affected zone (HAZ), crack formation, debris, and film delamination. The resulting morphological and microstructural changes that occur due to the high temperatures profoundly impact the properties and performance of solar thin films. In this regard, analyzing the material resolidification after melting and the formation of residue and debris particles are pivotal factors.

The heat-affected zone is one of the dominant thermal impacts in laser scribing. HAZ refers to the region surrounding the scribe line, where the material has been affected by the heat but has not been completely removed. It has been a critical challenge for researchers in scribing solar thin films because it can lead to microcracks, structural changes, and reduced efficiency. In the case of ns laser ablation, there is a noticeable extension of the HAZ in the neighboring region, where higher melting edges and bulges can be detected [87]. It has been widely accepted that ultrashort pulse lasers, especially fs lasers, have an excellent capability of reducing the HAZ [88]. However, to minimize the HAZ, various other methods have been developed.

The results from beam shaping experiments indicate that a top-hat beam shape could yield a considerably smaller HAZ compared to a Gaussian-shaped beam in thin film laser scribing. It is shown that despite the top-hat beam causing an approximately 20% increase in scribing width, the HAZ can be reduced by more than 83%. This outcome suggests that utilizing a top-hat beam shape can be a promising technique for reducing HAZ [89].

From this point of view, induced ablation could minimize the HAZ and melted areas according to the research performed on the P1 ablation of the Mo back-contact layer [25]. Bucher et al. [90] showed that the relationship between laser fluence and the extent of the HAZ in induced P1 ablation typically follows a V-shaped plot. The HAZ is relatively high at low fluences and can increase significantly at high fluences [90,91]. However, at a mid-range fluence, stress-assisted mechanical ablation is dominant, and it can minimize the size of the HAZ [90]. Moreover, lift-off ablation can be a great fit for scribing the CIGS absorber layer due to its high sensitivity to heat-induced damage even with ultrashort lasers; rear-side ablation with pressure through the Mo layer can be beneficial in this case [32]. Furthermore, new findings regarding this process indicate that enlarged laser beams may be used to avoid damage to the ITO because of the lower absorber-ITO interfacial temperature in P2-induced ablation [65].

Thermal stress, delamination, and cracking are other common phenomena that can be generated due to the localized temperature rise and thermal expansion in thin-film laser scribing. The significance of this phenomenon stems from its negative impact on power efficiency, cell viability, and photocurrent generation [92,93]. Using a ns laser source for P3 ablation in a-Si solar cells has shown irregular scribe boundaries with peeling of the film [94]. Other studies confirm these outcomes for Mo thin-film ns laser ablation with burr formation and microcracks due to thermal effects [95,96]. Figure 5 shows damage in the underlying Mo layer caused by thermal stress that results in cracking, bulging, and delamination [60]. This challenge was observed in the P3 laser scribing at the CZTSe and Mo interface [97].

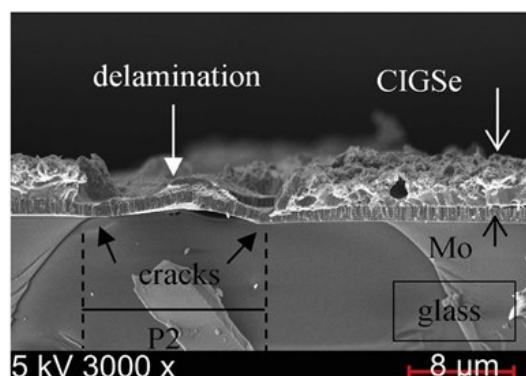


Figure 5. Cross-sectional SEM image of ps laser ablation of CIGS with crack formation, delamination, and bulging at the Mo underlying layer [60].

It has been shown that even employing ultrashort pulse lasers could not completely eliminate these defects for a-Si P2 scribing [98,99]. In this case, using infrared wavelength and high laser power increased delamination and elevated the molten rim in the surrounding edges in ps laser scribing [98]. Using glass-side laser ablation produced more delamination and microcracks due to the pressure created by the plasma expansion, which caused shockwave formation, film deformation, and brittle material cracking. New findings show that crack formation can also depend on the obtained groove profile; groove shapes with sharp vertical edges are more prone to void formation, cracking, and peeling-off in the deposited material than gradually sloped edge scribes [54].

Delamination can also be created in CdTe solar cell P2 lift-off ablation between the CdTe and CdS layers [93]. The weak adhesion between the layers can cause lateral delamination. In this case, microcracks, voids, and dislocations can be created at the tip of the delamination, as can be observed in the cross-sectional TEM images of the CdTe/CdS interface in Figure 6. This issue can be challenging since it can highly impact the long-term stability of solar thin films [46]. To overcome this barrier and minimize sheet resistance, operating at a mid-range fluence (3 J/cm^2) is recommended [93]. In total, careful optimization of laser parameters plays a significant role in controlling thermal and stress-assisted damages in solar thin-film laser scribing.

In laser scribing processes, the material is exposed to high temperatures generated by the laser beam, leading to melting and subsequent cooling and solidification. The process of solidification after melting is referred to as resolidification, which involves the formation of a new microstructure. However, during this change, the solidification process can capture nanovoids and bubbles and trigger crack formation in the material [39,100,101]. Using pump and probe techniques, researchers could observe that melt pool formation and subsequent resolidification typically occur in a few tens of ns, and side-view shadowgraphic measurements also showed complete resolidification dynamics at 250 ns [102,103]. Employing ns laser ablation showed significant residues inside the scribe with distinct resolidified areas near the scribe line in CIGS laser ablation, but ps laser produced much cleaner trenches [80]. Three-dimensional microscopy revealed that resolidified droplets and residuals inside the trench exhibited uneven scribe profiles [104]. Furthermore, UV laser pulses have shown better capabilities in reducing droplets and debris than longer wavelength pulses [105].

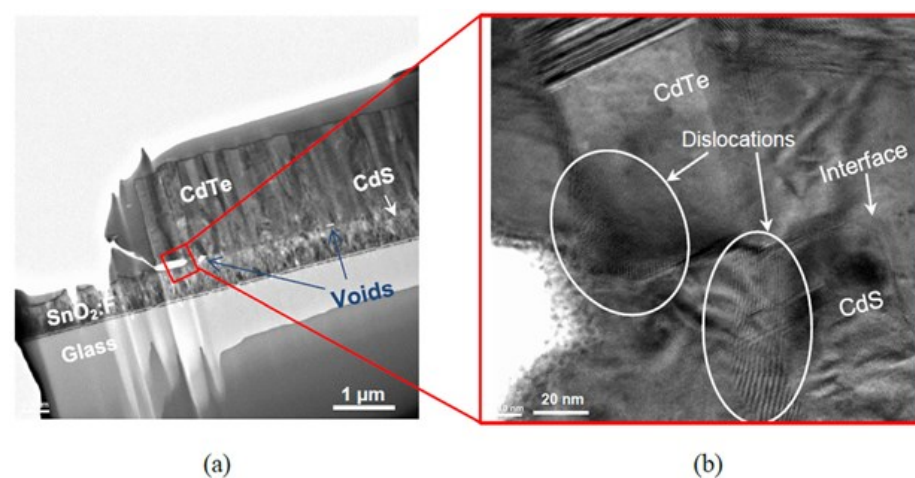


Figure 6. Cross-sectional TEM images of (a) the scribe boundary and (b) magnified image at the delamination tip, showing dislocations formed at both between the two layers and grains, which may introduce further crack initiation [93].

Using ultrashort pulse lasers has demonstrated good capability in minimizing debris in the P1 scribing of CIGS [106]. For perovskite scribing, it has also been shown that using a ps instead of ns laser could decrease needle-like PbI_2 residues, the typical byproduct of perovskite's thermal decomposition in the groove [78,107]. An optimum laser fluence was found to be more desirable since scribing in low fluence could leave a poorly scribed trench with melting and residues [108,109], and in higher fluence, solidified rims, bubbles, and splashes may remain. This phenomenon is shown in Figure 7 in both ns and ps laser scribing [108]. Higher pulse repetition rates could generate more voids and residues at the trench [110]. Furthermore, a top-hat beam could be more promising in minimizing residues, recast, and debris in laser scribing than a Gaussian beam [84,111].

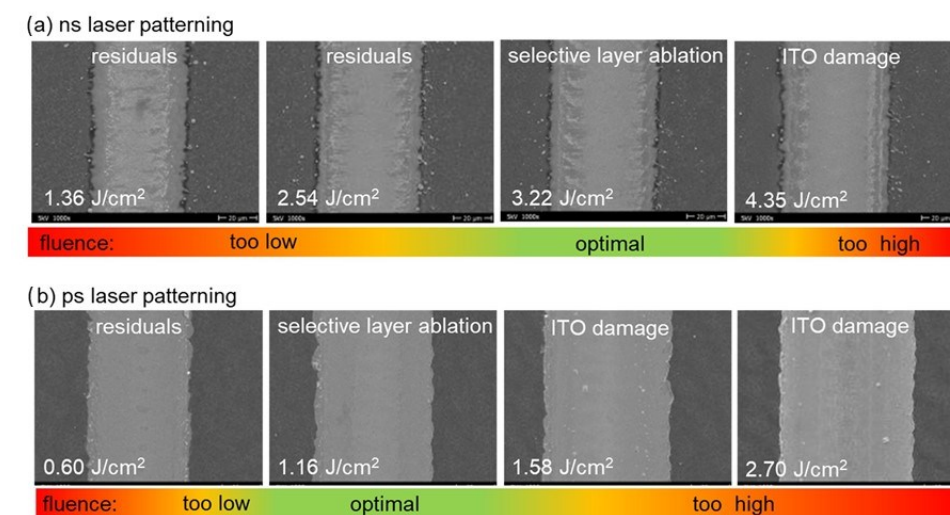


Figure 7. SEM images of (a) ns and (b) ps laser patterned P2 scribe-lines at different fluences (the magnification of all images: 1000 $\times$) [108].

The use of induced ablation can significantly reduce the residual formation and re-deposited material due to the prevention of plasma shielding and the protection of the film/carrier interface from debris. However, particular challenges associated with this procedure must be addressed [17,41,74]. Similar to direct ablation, there is an optimum value for laser fluence. Ablating film at lower and higher fluence can cause material melting and resolidification with the formation of nanobubbles and rims; this phenomenon has been captured in AZO, SnO_2 , and CdTe/CdS lift-off ablation [87,93,112]. In addition, increasing the overlap ratio to an optimum value has been recommended regarding residue [112].

Results obtained in [113] revealed that droplets and debris in the P2-induced ablation of perovskite could create a broad line of residues in the center of the groove. For minimizing residue and recast layers, combining the lift-off process with a fs laser can be a practical approach to attaining a debris and damage-free surface in laser scribing of an a-Si solar cell [114]. Alternatively, using an elliptical beam in combination with the lift-off process has attained clean scribes with minimum residues [65].

4.3. Chemical Composition and Reaction

Laser scribing of solar thin films may induce chemical modifications to surface and subsurface materials, necessitating chemical analysis as an essential investigative technique to discern and understand their effects on cell performance. Diffusion and phase transformation at the interface are common phenomena that can occur during the process due to the high temperature and thermal gradient induced by the laser beam. Additionally, the high temperature generated by the laser can also cause oxidation in both the metallic elements of the absorber layer and the metallic conductive films.

For complex multicomponent materials such as CIGS and CZTSe, the laser heat effect can cause the formation of secondary phases [97,115]. One of the most important front contact layer damages in these solar thin films is linked to considerable intermetallic diffusion and phase transformation occurring at high temperatures of the absorber–TCO interface or during the molten stage in P2 ablation. The key objective in CIGS P2 ablation is to limit the spread of unwanted intermetallic CIGS constituents towards the upper surface of the bottom contact film during the P2 scribing procedure, as this is necessary for preserving low contact resistance [65].

It has been observed that ns laser scribing of the CIS absorber layer can cause interdiffusion between resolidified CIS and Mo. In contrast, ps laser scribing could minimize interdiffusion and secondary phase formation [116,117]. Furthermore, laser scribing can cause partial evaporation. In this regard, creating a groove for P2 CIGS through laser scribing, which results in an abundance of resolidified conductive materials such as copper and a reduced presence of non-conductive elements residue, such as selenium, is not undesirable, because it can increase conductivity in the P2 trench [60,118]. A study investigated the effect of laser fluence (0.28–0.73 J/cm²) on the phase transformation during P2 scribing of CIGS. It was reported that scribing in an intermediate fluence caused metal elements enrichment and reduced Se element on the bottom contact layer and scribing walls, which could reduce resistance in the scribing groove. This study found the optimum fluence at 0.36 J/cm², and increasing or decreasing fluence increased Se and reduced metallic elements in the residues [60].

For P3 processing of CIGS solar cells with a ps laser, it has been shown that scribing both the back contact layer and absorber film can generate conductive phases, such as Mo, at the scribing edges that can connect back and front contact instead of isolation. Scribing only the upper conductive layer seems more efficient due to the lack of Mo exposure on the walls [119]. Better performance for removing only the back contact layer in the P3 scribe has also been confirmed for CZTSe solar cells [44]. Figure 8 shows the energy-dispersive X-ray spectroscopy (EDS) analysis of P3 scribing of CIGS and AZO with a cumulative thickness of about 1.95 µm. It can be observed that in a partial removal (1.3 µm), due to high intensity in the center of the groove, Mo diffusion inside the scribe can be detected (Figure 8a). It also can be seen that in the complete ablation of 1.95 µm, indium is almost removed entirely and Mo diffusion increases effectively with starting diffusion of Si element of the glass substrate (Figure 8b) [120].

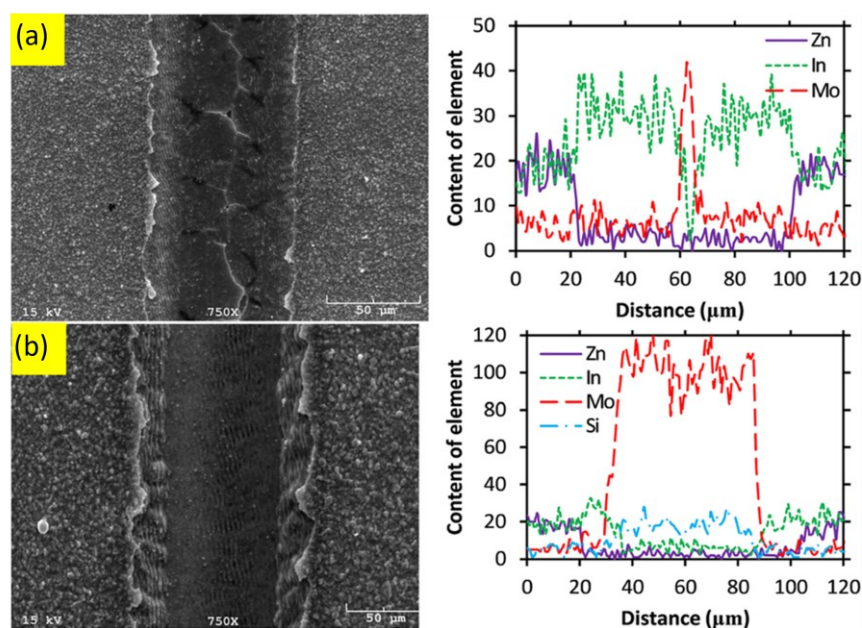


Figure 8. SEM image (left), and EDS measurement (right) of the slot; (a) laser fluence: 4.5 J/cm², overlap ratio: 81%, ablation depth: 1.3 µm, (b) laser fluence: 4.5 J/cm²; overlap ratio: 87%; ablation depth: 1.95 µm [120].

The diffusion of material during laser scribing can be affected by the composition of the absorber material, which can alter the bandgap and absorption properties of the material. Figure 9 illustrates the effects of Ga concentration (x_{Ga}) in the CIGS layer scribing at different laser fluences [109]. It is shown that $x_{\text{Ga}} > 0.2$ is more effective in reducing residues and secondary phase creation. Scanning electron microscopy (SEM) images illustrate that scribing using high laser fluence may lead to unfavorable outcomes and suboptimal scribes, accompanied by the presence of secondary phases [109].

Diffusion can also occur in perovskite solar cells, which was proved in the Raman spectra in a study of laser scribing using a ns Gaussian beam. Due to the Gaussian beam intensity profile, ITO residue was detected at points near the P2 scribe center, and using pulse energy of about 2 µJ was able to mitigate the issue [84]. For P3 scribing, gold flakes could be detected, creating a short circuit between the two adjacent sub-modules. Using higher fluence also showed a suitable ability to minimize this problem [20].

It has been discovered that ps laser scribing can initiate perovskite compositional change up to 4 µm away from the P3 scribe in the active area, and the changes in the composition of the perovskite layer adjacent to the scribe line were due to the existence of PbI₂ grains [11]. Compositional analysis in a ns laser scribing study showed a large amount of needle-shaped PbI₂ produced in the P3 scribe and a thin Br-rich layer formation at the perovskite/HTL interface extended up to 12 µm from the edge of the P3 line [78]. Figure 10 displays SEM images for ns and ps P3 perovskite scribing. The needle-shaped grains are identified as PbI₂. It can be inferred that ns pulses can readily generate both PbI₂ residues and a Br-rich layer, which passivate electronic defect states located at the edges of the scribe line and impede the movement of charge carriers in the surrounding regions [78]. However, it should be indicated that PbI₂-containing debris in P2 scribing is not desirable since it can lead to comparatively weak conductivity and impede low-resistance contact [113].

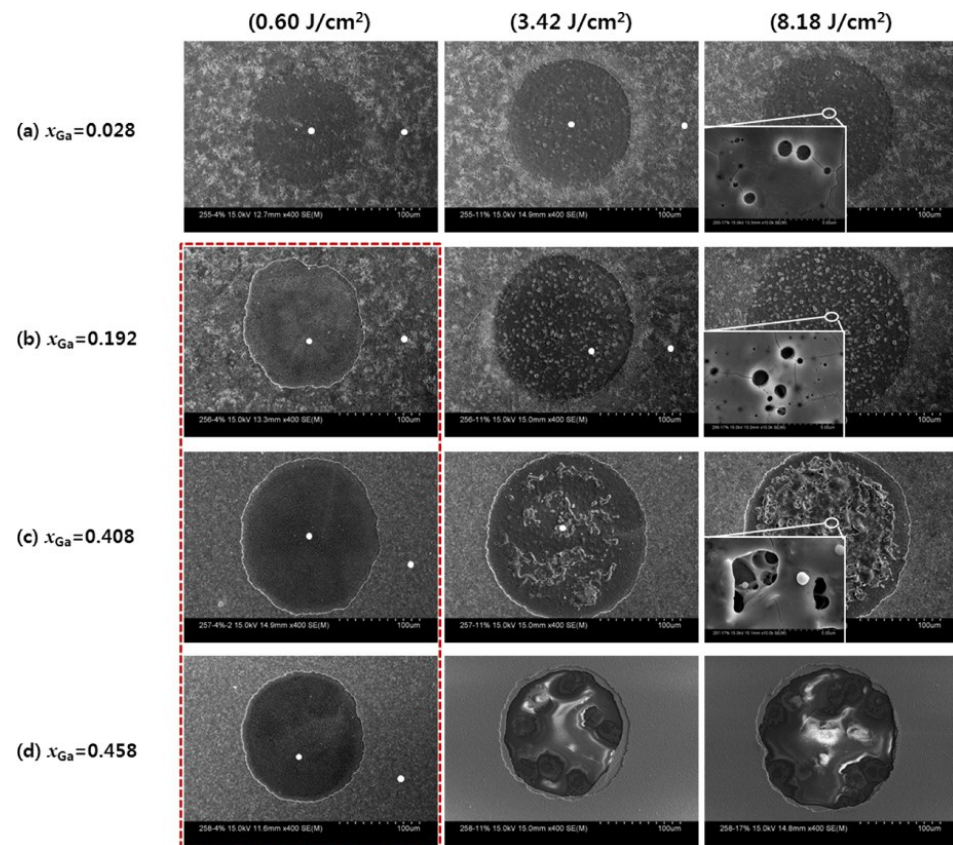


Figure 9. SEM images of the craters produced on the CIGS samples with different Ga concentrations at varying laser fluence [109].

Furthermore, in the case of laser scribing of metallic layers in reactive environments, such as air, precautions must be taken to avoid inter-pulse chemical reactions that can result in changes to the surface chemistry, such as oxidation, that can leave oxide deposits inside the groove and thus increase ohmic losses [17,88,121]. These reactions can also occur in solar cells with a buffer layer of CdS. The oxidation of sulfur can occur rapidly, resulting in its conversion into a gaseous phase. It can become stuck within the CdS matrix, where it may form bubbles upon secondary phase formation, which can ultimately create microcracks and weaken the electrical properties of the solar cell [93].

A double scribe method with UV ns laser has been proposed to minimize potential oxidation in laser scribing and reduce contact resistance in the P2 scribe. It has been demonstrated that the first scribe leaves a large amount of absorber oxide deposits inside the groove, and the second scribe removes most of them and leaves a minimum SiO₂ phase in the trench [122]. In this context, laser scribing in a vacuum with a pressure of 1.5×10^{-5} mbar as an alternative way has shown much cleaner scribes with fewer residues and lower resistance [70,123]. In order to avoid the formation of undesired oxides and degradation of perovskite material due to oxidation, laser patterning has also been performed inside a glovebox filled with nitrogen. As a result, the scribes were clean and free from any residual material [124].

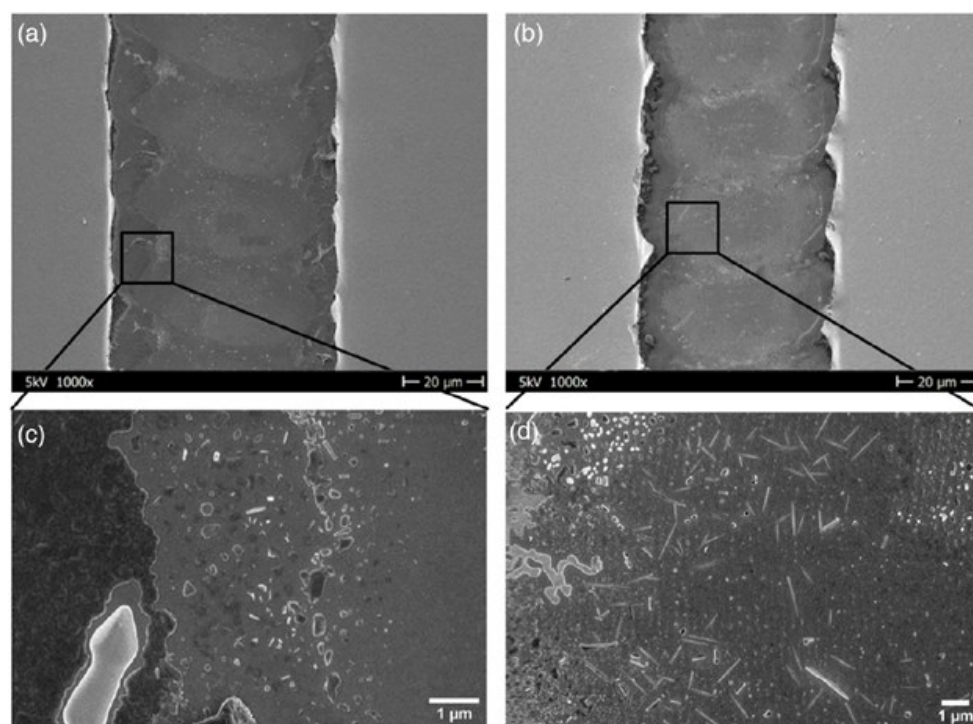


Figure 10. SEM images of the laser-scribed lines patterned by (a) ps and (b) ns laser pulses with fluences of 2.31 and 1.36 J cm⁻², respectively. The black squares schematically show the positions of the high-magnification images of the (c) ps and (d) ns laser scribe lines [78].

4.4. Electrical Characteristics

Preserving thin film solar PV efficiency from laboratory to industrial scale needs accurate control and selection of laser parameters and scribing techniques. Laser scribing could adversely impact the efficiency of solar cells by increasing the series resistance, decreasing their shunt resistance, and ultimately reducing the fill factor. These effects result from nonselective ablation and thermomechanical damage to underlying layers of the solar cell and the creation of new electrical paths through the cell, leading to current leakage and reduced performance [125]. Therefore, finding suitable laser parameters and techniques is crucial to minimize the efficiency loss due to laser scribing.

There is a direct correlation between increasing efficiency and decreasing dead area; however, ohmic losses and shunt formation should be considered. It has been reported that reducing dead area from 430 to 230 μm enhanced cell efficiency from 13.6% to 15.2% [80]. On the other hand, it has been shown that decreasing the P1 scribe width from 100 to 10 μm may not change the electrical properties of the line and cell [105]. However, module electrical properties may depend more on P2 and P3 scribing quality than on P1 scribing. In this regard, while Kubis et al. [58] declared that the interconnection width of 17 μm may be enough to ensure current transport without loss in the P2 scribe, the experimental results in another research showed that modules with a narrow P2 scribe of about 40 μm and a P3 scribe as narrow as 30 μm in perovskite solar cells could result in drop off in current and decrease in voltage [86]. Table 1 shows the combinations of P2 scribe widths ($a = 40$, $b = 160$, and $c = 320$ μm) with P3 scribe widths ($\alpha = 30$, $\beta = 90$, and $\gamma = 150$ μm) and their J–V (current–voltage) characteristics. The highest performing result occurs in “bβ” with a geometrical fill factor of 91% and power conversion efficiency (PCE) of 18.71%. It can be inferred that increasing the geometrical fill factor (GFF) from 91% to higher values decreases efficiency due to ohmic losses. Therefore, studying groove quality with consideration of material characteristics is necessary to correlate inactive area reduction and solar cell efficiency.

Table 1. J–V parameters of each module type fabricated. V_{oc} (open-circuit voltage) is calculated as the sum of three connected cells in series, I_{sc} is the short-circuit current, and J_{sc} is the short-circuit current density. Adapted with permission from [86].

Module Type	J_{sc} (mA cm ⁻²)	I_{sc} (mA)	V_{oc} (V) (Three Cells)	FF (%)	GFF (%)	PCE (%)
a α	21.4	16.05	3.015	78.31	95	16.84
a β	21.5	16.12	3.24	76.82	94	17.83
a γ	21.8	16.35	3.27	75.91	92	18.03
b α	22.1	16.57	2.99	75.25	92	16.55
b β	22.3	16.72	3.32	75.83	91	18.71
b γ	22.4	16.80	3.28	74.90	90	18.37
c α	22.4	16.81	3.06	73.81	89	16.89
c β	22.6	16.95	3.28	70.21	88	17.34
b γ	22.5	16.87	3.27	68.91	87	17.10

For P2 and P3 scribing, it has been demonstrated that direct laser scribing below the damage threshold can create a shunt between layers, which can damage the p–n junction [125]. This damage can be intensified using lasers with low beam quality (M^2). It was shown that using Nd:YAG lasers with $M^2 > 1.6$ could generate poor-quality scribes with residuals such as Sn and In in CdTe solar cells. These elements could diffuse and reach the junction area to create defects and increase electrical shunts, leading to a reduction in the parallel resistance (R_{sh}) of the device [74].

To reach high efficiency, high groove resistance is needed for P1 and P3 and low resistance for P2. Increasing laser fluence was found to promote complete ablation and elevate line resistance in P1 and P3 scribes [9,87]. However, high laser fluence may result in damage to the underlying layer due to overheating. It may also leave a resolidified layer, which could contribute to the formation of a substantial shunt and the undesirable reduction in parallel resistance [126]. Therefore, careful selection of optimum and suitable conditions for laser fluence in solar thin film scribing is needed. Figure 11 demonstrates how this could be done by studying the relationship between laser fluence and power conversion efficiency in the P3 scribing of perovskite solar cells [78].

To decrease defect and shunt formation in the scribes, using top hat beams and ultrashort pulse lasers can be more efficient [127]. Due to selective ablation and lower temperatures generated in top-hat beam laser scribing compared to Gaussian beam, diffusion, secondary phase formation, and damage to underlying layers can be minimized to achieve better electrical characteristics [89,111]. The application of ultrashort laser pulses has the potential to reduce the formation of defects at the scribing edges of a profile, thereby circumventing the negative impact of such defects on the electrical characterizations of the material [80]. It has been observed that ablating with a ns laser leads to formation of a liquid layer and residues of non-ablated material, particularly concentrated in the bordering zone of the ablation channel in P3 patterning. This zone contains metal residues in contact with the ZnO layer, causing a shunt between the Mo and ZnO layers. Using ns lasers may noticeably decrease the efficiency of the solar thin films, and ps and fs lasers have demonstrated much less efficiency drop in thin film solar cells [116,128].

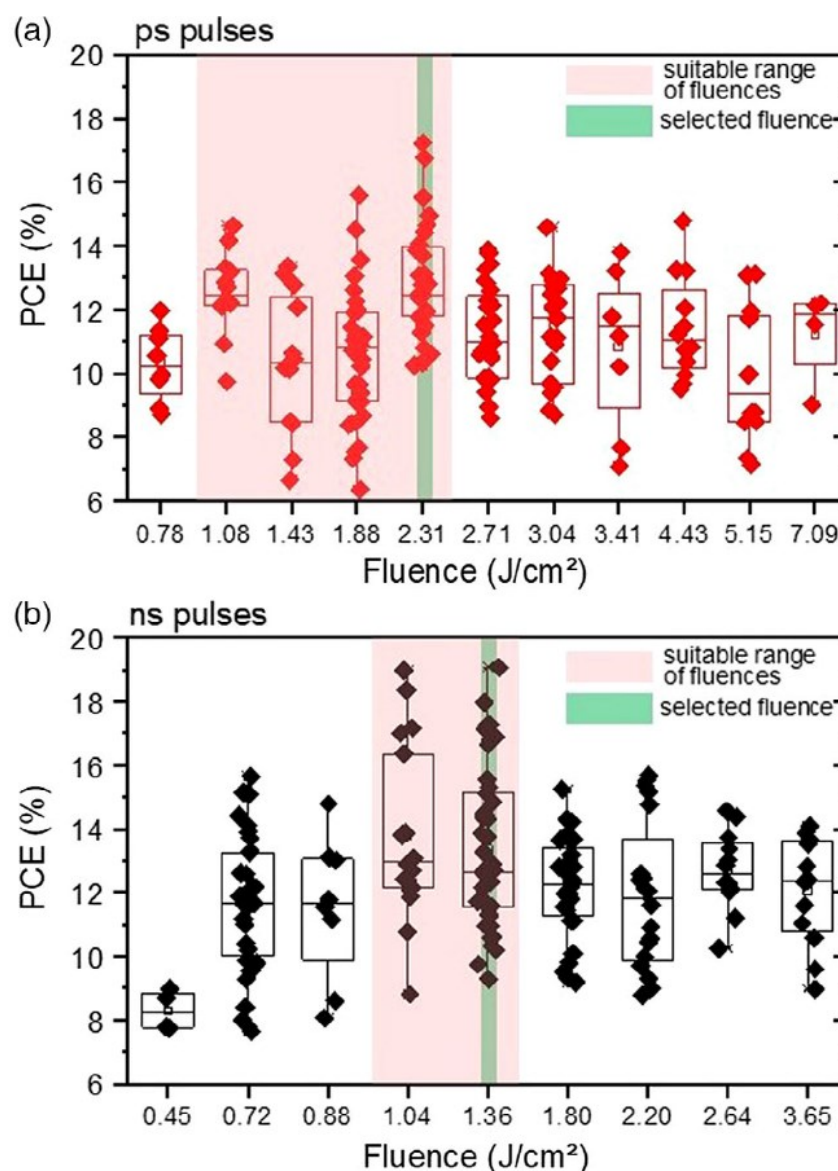


Figure 11. Box-plot of the mini-module PCE as a function of the applied laser fluence for P3 patterning by (a) ps and (b) ns laser pulses [78].

Furthermore, it must be mentioned that laser-type selection depends on the type of scribing and the film material to be removed. In P2 scribing of perovskite, a ns laser is not desirable since it can generate non-conductive materials such as residues and debris. However, it can be beneficial in P3 scribing, where high isolation and resistance are demanded [78,113]. This selection strategy is also effective in multi-compositional materials such as CIGS and CZTSe. Additionally, the researchers have observed that the implementation of the lift-off process in conjunction with ultrashort pulsed laser ablation did not result in any noticeable degradation of the electrical properties of the thin film solar cells, which is attributed to the effective mitigation of secondary phase formation and structural disorders within the trench [44]. However, indirectly induced ablation of CZTSe using ps and fs lasers has shown contradictory results. It was found that scribing CZTSe with a 300 fs laser caused nonlinear absorption effects leading to a higher P3 line conductivity and reduced efficiency compared to using a 60 ps laser [97]. Along with laser pulse width and scribing method, choosing a suitable wavelength based on the optical properties of the material is necessary. For example, ps laser scribing of CIGS caused less efficiency drop with infrared wavelength than green wavelength due to less melt formation and heat

effects at the scribing edge. However, for P3 scribing of CIGS, green lasers showed better performance [116,129].

For P3 patterning of CIGS, as shown in Figure 12, type 1 scribing, which removes both the absorber and the front contact layer at a 200–1000 kHz repetition rate, has higher scribe conductance than type 2 scribing of the front contact layer only at a 100 kHz repetition rate [129,130]. The phenomenon can be attributed to a significant increase in the amount of the resolidified conductive layer within the type 1 groove [131]. Eventually, it has resulted in a lower fill factor value and efficiency for type 1 scribing [132].

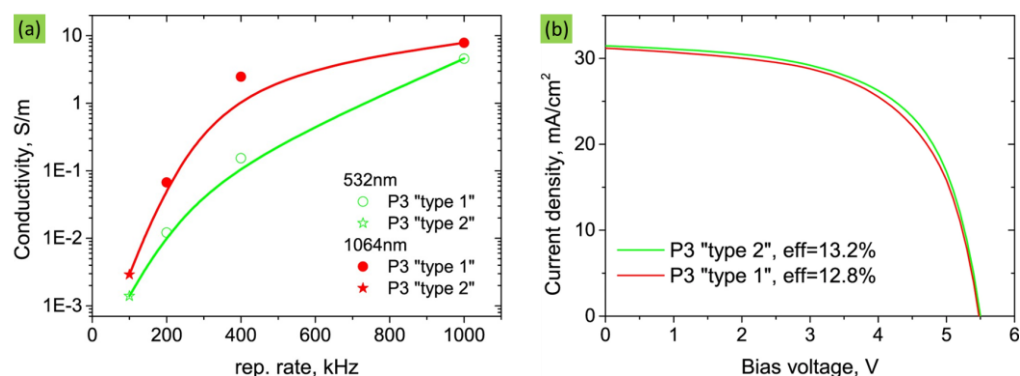


Figure 12. (a) Laser scribe conductivity based on laser repetition rate for P3 type 1 and type 2, (b) module electrical performance for type 1 and 2 [129].

Two other methods have also been used for laser scribing of solar thin films to enhance conversion efficiency. The first technique is a combination of thermal annealing with femtosecond laser scribing. It has been shown that thermal annealing in a moderate temperature range between 50 and 200 °C after laser scribing can boost power conversion efficiency, as verified by J–V curve measurements before and after annealing. The enhancement in the efficiency of the solar thin film is attributed to the removal of defect states induced by the laser, which are concentrated in high densities near the p–n junction and the edges of the scribe [133]. A two-pass laser scribing is the second method for increasing solar thin film efficiency. The idea is to use the second pass to remove the high amount of debris left inside the trench from the first pass. The efficacy of this approach was demonstrated in a study of ns laser scribing of perovskite solar cells by comparing the scribing quality before and after the second pass. It can be inferred that by employing this technique, solar cell efficiency can be positively impacted with minimum resistive losses [68].

5. Summary and Outlook

In conclusion, laser scribing has shown great potential in enhancing the performance of solar thin films by enabling the fabrication of highly precise and efficient scribes. Despite the significant progress made in this century, the difference in power conversion efficiency between small-scale solar cells and large-area solar modules remains a critical challenge. Achieving a high geometrical fill factor by reducing the dead area is fundamental to minimizing efficiency loss. However, reducing the dead area does not guarantee efficiency improvement since it is accompanied by various defects and challenges that can create more electrical losses. The primary defects include incomplete ablation, HAZ, damage to underlying layers, microcracks, secondary phase formation, and residues inside the trench.

According to this review, laser pulse duration is highly effective in overcoming these barriers and significantly minimizes efficiency losses by improving the quality of laser scribing. Using ultrashort pulse lasers is necessary for selectively ablating the entire layer, avoiding damage to the underlying films, creating more consistent and cleaner scribes, and minimizing flake formation and delamination compared to ns laser sources. They also

have excellent capabilities in reducing the HAZ and minimizing residues in the scribes. However, using a ns laser can still be a practical technique in some cases, particularly for materials with low thermal diffusivity, such as perovskite solar cells. Nanosecond laser can create scribes with more nonmetallic materials to generate better isolation, especially in P3 scribing of perovskite. Nevertheless, using a ns laser can lead to irregular scribe boundaries with film peeling, burr formation, and microcracks due to thermal effects, which can influence the durability and efficiency of solar thin films. Therefore, a laser source with a suitable pulse duration should be selected based on the required geometrical requirements of the scribes, the material's thermal and optical properties, and other specific characteristics of the patterning type. Additionally, more research studies are needed to distinguish scribing quality between using ps and fs lasers since there are controversial results.

Regarding beam quality, laser sources with a better beam quality factor M^2 (<1.3) have been found to produce narrower and higher-quality scribes. Laser fluence is another key parameter that significantly impacts the quality and efficiency during solar thin film laser scribing. Inadequate laser fluence can result in poor-quality scribes, including surface bulging, while excessive fluence can damage the back contact layer due to overheating and nonlinear absorption. Additionally, increased laser fluence can trigger undesired secondary phase formation, especially in P2 scribes. It is suggested to use a moderate range of laser fluence to attain stress-assisted mechanical ablation, which can diminish the size of the HAZ. To avoid incomplete scribes, high rims, and bubbles, researchers preferred to employ an optimal laser fluence value; this condition has resulted in the enrichment of metallic elements and the reduction of non-conductive elements in CIGS P2 scribing, which decreases electrical resistance in the scribe.

For homogeneous laser scribing, high laser overlapping ratios are demanded. In this regard, elliptical beam shaping constitutes an excellent asset to enable reduced overlapping ratios and heat accumulation. Elliptical beam shaping seems promising in narrowing laser scribe width and dead area and decreasing thermal and phase transformation-related damages. Therefore, using an elliptical beam, especially in combination with lift-off ablation, is recommended to optimize the process; however, electrical and resistance measurements are necessary for future studies to validate this method. Top hat beam shaping is also a practical technique to obtain steep-walled grooves, which is also beneficial in ns laser ablation to homogeneously distribute heat in the entire groove rather than in the center of the groove as for typical Gaussian beams.

Furthermore, lift-off ablation has shown great potential for mass production since it can produce steep scribes with minimum ablation energy usage and decreased thermal damage and debris inside the scribe. However, crack formation and layer delamination, especially in P2 and P3 ablation, can generate shunts inside the groove and result in unfavorable monolithic interconnections, a great risk for the long-term stability of the solar cells. In this context, employing appropriate laser parameters to reach a combined thermal and mechanical ablation is suggested. Moreover, optimizing the process to reduce scribe width and increase groove uniformity with this method is necessary. In future studies, beam shaping methods, jointly with lift-off ablation, can be studied for reducing microcracks and film separation.

For reducing dead area, fs laser scribing has reached a remarkable groove width of a few micrometers. However, electrical characteristics evaluation is highly demanded to analyze the J–V curve and ultimate efficiency drop for such narrow scribes. Point contact interconnections design is promising for effectively reducing the dead area. This approach has a great capability to reach a geometrical fill factor of up to 99%. However, current losses in P2 ablation in this structure may be a critical challenge, and more work is needed to assess the feasibility of this technique.

For future research, it is also recommended to investigate laser scribing of new generation solar thin films with nanomaterials such as quantum dots or 2D materials. Laser scribing of bifacial solar cells also needs to be studied. Investigation into decreasing the

dead area in perovskite solar cells without electrical losses is another vital issue that should be addressed in the future.

Finally, to achieve high quality laser scribing with the capability of high-speed production in industrial applications, scribing with advanced optics could be a case of future study. This case study may employ beam shaping methods, such as the Bessel beam and elliptical beam, which have demonstrated excellent capability in high-speed laser scribing [65,134]. Implementation of these advanced optical techniques is expected to lead to low manufacturing costs for industries. Furthermore, machine learning algorithms can be used to optimize laser scribing parameters, such as the laser power, pulse duration, and repetition rate, to achieve the desired surface integrity with high scanning speeds and better control of height variation toleration, especially during roll-to-roll laser scribing.

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